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<u>CLAIMS</u>

What is claimed is:

- 1. A method of forming a semiconductor-on-insulator structure, comprising the steps of:
 - a) forming a structure having porous semiconductor material at a first surface thereof;
- b) introducing an oxidizing species into said porous semiconductor material; and, either before or after step b),
 - c) forming an epitaxial semiconductor layer on said porous semiconductor material, and reacting said oxidizing species with said porous semiconductor material to form a buried dielectric layer beneath said epitaxial layer.
 - 2. The method of Claim 1, wherein said oxidizing species consists essentially of oxygen.
 - 3. The method of Claim 1, wherein said semiconductor layer consists essentially of silicon.

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- 4. A method of forming a semiconductor-on-insulator structure, comprising the steps of:
 - a) anodizing a silicon wafer to form porous silicon;
 - b) introducing oxygen into said porous silicon; and, either before or after step b),
 - c) forming a semiconductor layer on said porous silicon, and reacting said oxygen with said porous semiconductor material to form a buried oxide layer.
- 5. The method of Claim 4, wherein said semiconductor layer consists essentially of silicon.
- 6. A method of forming a semiconductor-on-insulator structure, comprising the steps of:
 - a) partially anodizing a silicon wafer to form porous silicon; and thereafter
- b) forming an epitaxial semiconductor layer on said porous silicon; and thereafter
 - c) introducing oxygen into said porous silicon, and reacting said oxygen with said porous silicon to form a buried oxide layer.
- 7. The method of Claim 6, wherein said oxidizing species consists essentially of oxygen.
 - 8. The integrated circuit of Claim 6, wherein said semiconductor layer consists essentially of silicon.

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- 9. A product made by the process of Claim 1.
- 10. A product made by the process of Claim 4.
- 15 11. A product made by the process of Claim 6.

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